



# Reliability Qualification Report

for

**DDR3L SDRAM with Pb/Halogen Free**

**(256M×16, 25nm SDRAM  
AS4C256M16D3LC-10BCN/AS4C256M16D3LC-12BCN)**

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**Reliability Qualification Report for  
 AS4C256M16D3LC-10BCN/  
 AS4C256M16D3LC-12BCN**

**(256M x 16 DDR3L SDRAM with Pb/Halogen Free)**

**0. RELIABILITY TEST SUMMARY**

Test Item	Test Condition	Pass Criteria	Test Result
EFR	1.2*Vint, 125°C, 48Hrs	0 - 1 (Year) ≤ 1000 (DPM)	0/1000 0 DPM (PASS)
OLT	1.1*Vint, 125°C, 1000Hrs	1 - 10 (Year)	0/231 15 FIT (PASS)
		≤ 50 (FIT)	MTBF= 67 x 10 <sup>6</sup> Hrs
MSLT	Level III	0/1 (A/R)	0/228 (PASS)
HTST	150°C, 1000Hrs	0/1 (A/R)	0/76 (PASS)
TCT	-65°C ~ +150°C, @3cph, 500Cycles	0/1 (A/R)	0/76 (PASS)
PCT	121°C, 100%R.H., 2.0atm, 96Hrs	0/1 (A/R)	0/76 (PASS)
HAST	130°C, 85%R.H., 2.3atm, 1.45V, 96Hrs	0/1 (A/R)	0/76 (PASS)
ESD	HBM: R=1.5KΩ, C=100pF	≥ ±2KV	0/3 (PASS)
	MM: R=0KΩ, C=200pF	≥ ±200V	0/3 (PASS)
	CDM: Non-Socket Mode	≥ ±500V	0/3 (PASS)
Latch-Up	Vtr (+) ≥ 1.5 * Vcc Vtr (-) ≤ -0.5 * Vcc Itr(+) ≥ 100mA Itr(-) ≤ -100mA		0/6 (PASS)

**Moisture Sensitivity Level Test Flow & Condition:**

Electrical Test → SAT → TC (-65°C ~ +150°C, 5Cycles) → Bake (125°C, 24Hrs) →  
 Soak Level III (30°C, 60%R.H., 192Hrs) → Convection Reflow (260 +5/-0°C,  
 0~20Secs, 3Cycles) → Electrical Test → SAT

## 1. INTRODUCTION

In order to meet the most stringent market demands for high quality and reliability semiconductor components, Alliance Memory maintains a strict reliability program in all products. The purpose of this report is to give an overview of the reliability status of AS4C256M16D3LC-10BCN/AS4C256M16D3LC-12BCN.

Accelerated tests are performed on product, and then the results are extrapolated to standard operating conditions in order to calculate and estimate the component's failure rate.

## 2. PRODUCT INFORMATION

The AS4C256M16D3LC-10BCN/AS4C256M16D3LC-12BCN is a 256M\*16 bits high-speed CMOS Double Data Rate Three Synchronous Dynamic Random Access Memory (DDRIII SDRAM) operating from a single 1.283 to 1.45 Volt power supply. By employing some new CMOS circuit design technologies and the advanced DRAM process technologies, the AS4C256M16D3LC-10BCN/AS4C256M16D3LC-12BCN is well suited for applications requiring high memory bandwidth and particularly well suited to high performance PC applications. The AS4C256M16D3LC-10BCN/AS4C256M16D3LC-12BCN is packaged in a standard 96ball, plastic 7.5x13.5mm wBGA.

## 3. RELIABILITY

Many stress tests have been standardized in such documents as MIL-STD-883, EIAJ-IC-121, EIA/JESD22 and JEDEC-NOTE-17. From these standards, Alliance Memory has selected a series of tests to ensure that reliability targets are being met. These tests, including life test, environmental test, ESD test and latch-up test, are discussed in the following sections.

### 3.1. Sample Preparation Flow

CP → Assembly 96B BGA → FT → Sampling Good Parts for Reliability Test

### 3.2. Life Test

The purpose of the Early Failure Rate (EFR) is to estimate the infant mortality failure rate that occurs within the first year of normal device operation by accelerating infant mortality failure mechanisms. The oven temperature for the EFR test is 125°C. Testing is performed with dynamic signals applied to the device, and the voltage is 1.2\*Vint.

The purpose of the Operating Life Test (OLT) is to determine the reliability of products by accelerating thermally activated failure mechanisms by subjecting samples to extreme temperatures under biased operating condition of 1.1\*Vint. The test is used to predict long-term failure rates in terms of FITs (failures in time), with one FIT representing one failure in 10<sup>9</sup> device-hours. The test samples are screened directly after final electrical testing. The oven temperature for the OLT is 125°C. Testing is performed with dynamic signals applied to the device, and the voltage is 1.1\*Vint.

#### 3.2.1. Test Flow

##### (1) EFR Test Flow

B/I 48Hrs (125°C, 1.2\*Vint) → Electrical Test (95°C & 0°C)

##### (2) OLT Test Flow

B/I 168Hrs (125°C, 1.1\*Vint) → Electrical Test (95°C & 0°C)

→ B/I 500Hrs (125°C, 1.1\*Vint) → Electrical Test (95°C & 0°C)

→ B/I 1000Hrs (125°C, 1.1\*Vint) → Electrical Test (95°C & 0°C)

#### 3.2.2. Test Criteria

Test Item	Reference Standard	Test Condition	Prediction Duration	Pass Criteria
EFR 48Hrs	JESD22-A108	Vcc= 1.2*Vint Ta= 125°C	0 – 1 (Year)	≤ 1000 (DPM)
OLT 1000Hrs		Vcc= 1.1*Vint Ta= 125°C	1 – 10 (Year)	≤ 50 (FIT)

### 3.2.3. Failure Rate Calculation and Test Result

The life test is performed for the purpose of accelerating the probable electrical and physical weakness of devices subjected to the specified conditions over an extended time period.

By choosing the appropriate thermal activation energy ( $E_a$ ), data taken at an elevated temperature can be translated to a lower standard operating temperature through the Arrhenius equation:

$$T(AF) = \text{Exp} [(E_a/k) * (1/T_n - 1/T_s)] \dots (1)$$

where

$T(AF)$  = Temperature Acceleration Factor

$T_n$  = Normal Temperature in Absolute Temperature (K)

$T_s$  = Stress Temperature in Absolute Temperature (K)

$k$  = Boltzmann's Constant ( $8.62 * 10^{-5}$  eV/K)

$E_a$  = Thermal Activation Energy

By choosing the appropriate electrical field acceleration rate constant ( $V_f$ ), data taken at an elevated voltage can be translated to a lower standard operating voltage through the Eyring model:

$$E(AF) = \text{Exp} [V_f * (V_s - V_n)] \dots (2)$$

where

$E(AF)$  = Electrical Field Acceleration Factor

$V_n$  = Normal Operating Voltage

$V_s$  = Stress Operating Voltage

$V_f$  = Electrical Field Acceleration Rate Constant

By combining the equation (1) & (2), the failure rate ( $\lambda$ ) can be calculated by using the following equation:

$$\lambda (FIT) = [(Lamda \text{ of } 60\% \text{ CL}) / (2 * TDH * AF)] * 10^9 \dots (3)$$

where

$\lambda$  = Failure Rate in FIT

AF= Acceleration Factor

$$= T(AF) * E(AF)$$

TDH= Total Device-Hours of the Test

$$= \text{Device No.} * \text{Hour}$$

Lamda of CL= 60% Confidence Level (Refer to the Following Table)

DF	Lamda
1	0.70
2	1.83
3	2.95
4	4.04
5	5.13
6	6.21
7	7.28
8	8.35
9	9.41
10	10.50

$$DF = 2 * (\text{Failure No.} + 1)$$

Therefore, from equation (3), we can get the FIT number for our OLT experiment. The MTBF can be also calculated from the reciprocal of the FIT rate multiplied by  $10^9$ .

### 3.2.3.1. EFR Test Result

A summary of Early Failure Rate (EFR) data for the AS4C256M16D3LC-10BCN/AS4C256M16D3LC-12BCN is listed in Table 1, where the total of 1,000 devices at 125°C has been collected with 0 failure.

Test Item	Sample	Test Result (Failure / Sample Size)	Failure Mode
		48 Hrs	
EFR	1000ea	0/1000 [= 0 DPM]	N/A

**Table 1. EFR Test Result for 0-1 Year Prediction**

### 3.2.3.2. OLT Test Result

A summary of Operating Life Test (OLT) data for the AS4C256M16D3LC-10BCN/AS4C256M16D3LC-12BCN is listed in Table 2, where the total of 231,000 device-hours at 125°C has been collected with 0 failure. We then use  $E_a = 0.5\text{eV}$  and  $V_f = 7.0(1/V)$  (a worse case value from Alliance Memory's foundry) to calculate the failure rate with a 60% confidence level. Table 3 shows the final result that the failure rate of 15 FIT at  $T_a = 55^\circ\text{C}$  and  $V_{cc} = 1.35\text{V}$  is predicted.

Test Item	Sample	Test Result (Failure / Sample Size)			Failure Mode
		168 Hrs	500 Hrs	1000 Hrs	
OLT	231ea	0/231	0/231	0/231	N/A

**Table 2. OLT Test Result**

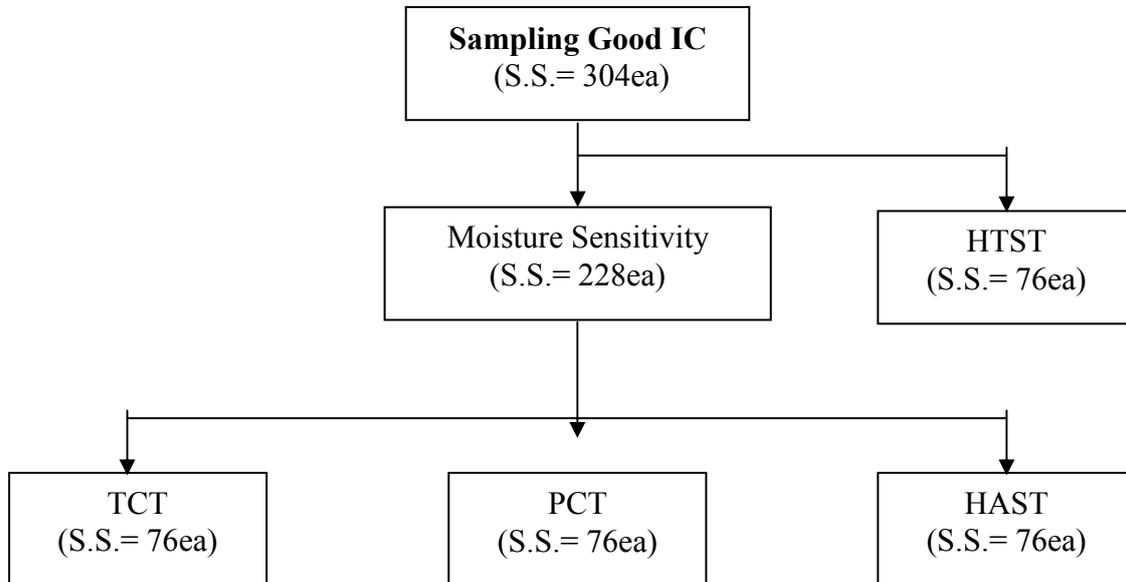
Sample	Device -Hours	Total Failure	Failure Rate Prediction ( $E_a = 0.5\text{eV}$ , $V_f = 7.0(1/V)$ )		
			55°C & 1.35V (% / 1000hrs)	$\lambda$ (FIT)	MTBF (Hr)
231ea	231,000	0ea	0.0015	15	$67 \times 10^6$

**Table 3. OLT for 1-10 Year Failure Rate Prediction**

### 3.3. Environmental Test

The purpose of environmental test is to evaluate the ability of semiconductor device to withstand the temperature stress, humidity stress, electrical stress or any combination of these. It can reveal not only the package quality issue but also the possible error in wafer process or chip design interacting with the assembly process.

### 3.3.1. Test Flow



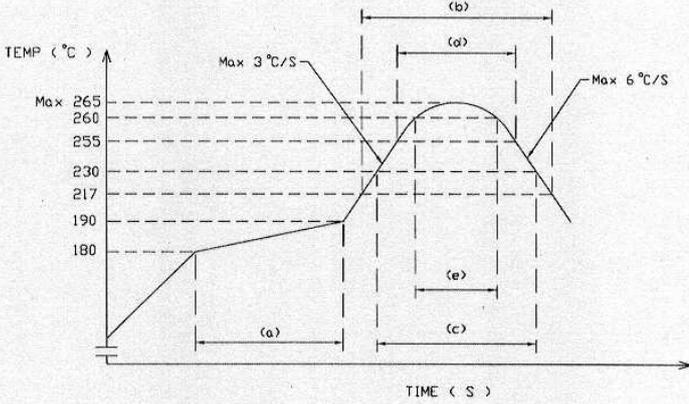
### 3.3.2. Test Condition and Time

#### 3.3.2.1. Moisture Sensitivity Test

The purpose of moisture sensitivity test is to identify the classification level of nonhermetic solid state Surface Mount Devices (SMDs) that are sensitive to moisture-induced stress so that they can be properly packaged, stored, and handled to avoid subsequent thermal and mechanical damage during the assembly solder reflow attachment and/or repair operation.

#### \*Moisture Sensitivity Test Flow

Electrical Test → SAT → TC (-65°C~+150°C, 5Cycles) → Bake (125°C, 24Hrs) → Soak Level III (30°C, 60%R.H., 192Hrs) → Convection Reflow (260 +5/-0°C, 0~20Secs, 3Cycles) → Electrical Test → SAT

Test Item	Test Condition (Level III)	Test Time
Temp. Cycle	-65°C ~ +150°C	5Cycles
Bake	125°C	24Hrs
Unbiased Temp-Humidity Soak	30°C, 60%R.H.	192Hrs
Convection Reflow	<p style="text-align: center;"><b>IR REFLOW PROFILE FOR 260 – 0 / +5°C (Pb-Free)</b></p>  <p>(a) Preheat Temp. = 60~120 seconds Max.            (b) Temp. maintained above 217°C = 60~150 seconds            (c) Temp. maintained above 230°C = 30~60 seconds            (d) Temp. maintained above 255°C = 20~40 seconds            (e) Peak Temp. Range = 260(-0/+5)°C &amp; Max. 20 seconds            P.S. Time 25°C to Peak Temp. = 8 minutes Max.</p>	3Cycles

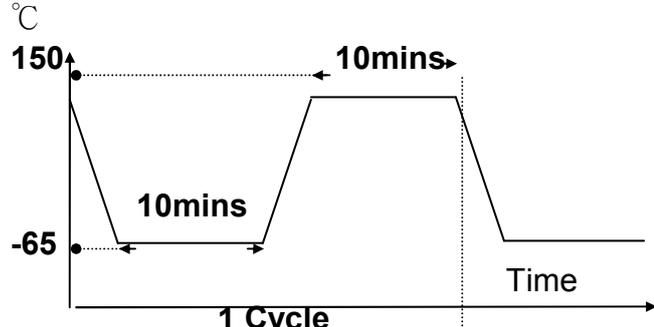
### 3.3.2.2. High-Temperature Storage Life Test

The high-temperature storage life test measures device resistance to a high-temperature environment that simulates a storage environment. The stress temperature is set to 150°C in order to accelerate the effect of temperature on the test samples. In the test, no voltage bias is applied to the devices.

Test Item	Test Condition	Test Time
HTST	150°C	1000Hrs

### 3.3.2.3. Temperature Cycling Test

The purpose of temperature cycling test is to study the effect of thermal expansion mismatch among the different components within a specific die and package system. The cycling test system has a cold dwell at  $-65^{\circ}\text{C}$  and a hot dwell  $150^{\circ}\text{C}$ , and it employs a circulating air environment to ensure rapid stabilization at a specified temperature. During temperature cycling test, devices are inserted into the cycling test system and held at cold dwell for 10 minutes, then the devices are heated to hot dwell for 10 minutes. One cycle includes the duration at both extreme temperatures and the two transition times. The transition period is less than one minute at  $25^{\circ}\text{C}$ . Samples of surface mount devices must first undergo preconditioning and pass a final electrical test prior to the temperature cycling test.

Test Item	Test Condition	Test Time
TCT	 <p>The graph shows a temperature profile over time. The vertical axis is labeled <math>^{\circ}\text{C}</math> and has markers for 150 and -65. The horizontal axis is labeled Time. The profile starts at 150°C, drops to -65°C, dwells at -65°C for 10 minutes, rises back to 150°C, dwells at 150°C for 10 minutes, and then drops to a lower temperature. A bracket labeled '1 Cycle' spans from the start of the first dwell to the end of the second dwell. The label 'Time' is at the end of the horizontal axis.</p>	500Cycles

### 3.3.2.4. Pressure Cooker Test

The pressure cooker test is an environmental test that measures device resistance to moisture penetration and the effect of galvanic corrosion. The stress conditions for the pressure cooker are  $121^{\circ}\text{C}$ , 100% relative humidity, and 2.0atm pressure. Samples of surface mount devices are subjected to preconditioning and a final electrical test prior to the pressure cooker test.

Test Item	Test Condition	Test Time
PCT	121°C, 100%R.H., 2.0atm	96Hrs

### 3.3.2.5. Highly-Accelerated Temperature and Humidity Stress Test

The highly-accelerated temperature and humidity stress test is performed for the purpose of evaluating the reliability of non-hermetic packaged solid-state device in an environment with high humidity. It employs severe condition of temperature, humidity, and bias that accelerate the penetration of moisture through the external protective material (encapsulant or seal) or along the interface between the external protective material and the metallic conductor that pass through it. The stress conditions of the HAST are 130°C, 85% relative humidity, 2.3atm pressure, and 1.45V maximum operating voltage. Samples of surface mount devices are subjected to preconditioning and a final electrical test prior to the highly-accelerated temperature and humidity stress test.

Test Item	Test Condition	Test Time
HAST	130°C, 85%R.H., 2.3atm, 1.45V	96Hrs

### 3.3.3. Test Criteria and Result

Table 4 shows the test results and reference standard of environmental test. The test status and results of AS4C256M16D3LC-10BCN/AS4C256M16D3LC-12BCN are also presented in the table. All pass from these test results mean that Alliance Memory's SDRAM products are much more endurable in most of their service environment.

Test Item	Reference Standard	A/R Criteria	Failure/S.S.	Status	Failure Mode
Moisture Sensitivity	J-STD-020	0/1	0/228	PASS	N/A
HTST	JESD22-A103	0/1	0/76	PASS	N/A
TCT*	JESD22-A104	0/1	0/76	PASS	N/A
PCT*	JESD22-A102	0/1	0/76	PASS	N/A
HAST*	JESD22-A110	0/1	0/76	PASS	N/A

\* **Sampling from Moisture Sensitivity**

**Table 4. Environmental Test Criteria and Result**

### 3.4. ESD Test

Electrical discharge into semiconductor product is one of the leading causes of device failure in the customer's manufacturing process. Alliance Memory performs the ESD test to ensure that the performance of AS4C256M16D3LC-10BCN/AS4C256M16D3LC-12BCN will not be degraded to an unacceptable level by exposure to a succession of electrostatic discharge. The test methods and test results are shown in Table 5.

Test Item	Test Method				Result (F/S.S)
	Reference Standard	Test Condition	Criteria	Sample	
H.B.M.	JESD22-A114	R=1.5K $\Omega$ , C=100pF	$\geq \pm 2KV$	3ea	0/3
M.M.	JESD22-A115	R=0K $\Omega$ , C=200pF	$\geq \pm 200V$	3ea	0/3
C.D.M.	JESD22-C101	Non-Socket Mode	$\geq \pm 500V$	3ea	0/3

**Table 5. ESD Test Condition and Result**

### 3.5. Latch-Up Test

CMOS products can be prone to over-voltage exceeding the maximum device rating if the parasitic p-n-p-n SCRs (Silicon-controlled rectifier) are improperly biased. When the SCR turns on, it draws excessive current and causes products being damaged by thermal runaway. The Table 6 shows the latch-up test method and the test result of no failure.

Test Item	Test Method			Result (F/S.S)
	Reference Standard	Test Condition & Criteria	Sample	
Latch-Up	JESD78	$V_{tr}(+) \geq 1.5 * V_{cc}$ $V_{tr}(-) \leq -0.5 * V_{cc}$ $I_{tr}(+) \geq 100mA$ $I_{tr}(-) \leq -100mA$	6ea	0/6

**Table 6. Latch-Up test Condition and Result**

#### 4. CONCLUSION

Reliability test is to ensure the ability of a product in order to perform a required function under specific conditions for a certain period of time. Through those tests, the devices of potential failure can be screened out before shipping to the customer. At the same time, the test results are fed back to process, design and other related departments for improving product quality and reliability.

According to the life time test data, *the short-term 48Hrs failure rate (= the normal operation 0-1 year) of AS4C256M16D3LC-10BCN/AS4C256M16D3LC-12BCN is equal to 0 DPM at Ta=55°C and Vcc=1.35V with 60% confidence level AND the long-term 1000Hrs failure rate (= the normal operation 1-10 year) of AS4C256M16D3LC-10BCN/AS4C256M16D3LC-12BCN is equal to 15 FIT at Ta=55°C and Vcc=1.35V with 60% confidence level.* The results of environmental test, ESD test and latch-up test also ensure that AS4C256M16D3LC-10BCN/AS4C256M16D3LC-12BCN is manufactured under a precise control of quality work by Alliance Memory and its subcontractors. ***Thus, this experiment based on the Alliance Memory reliability test standard for above test items can all pass.***

With the extensive research and development activities and the cooperation of all departments, Alliance Memory continuously sets and maintains higher standard of quality and reliability to satisfy the future demand of its customers.